

IN THE CLAIMS:

Kindly replace the claims of record with the following full set of claims:

1. (Currently amended) An optical information storage medium comprising:
 - a carrier substrate;
 - a reflective information layer being positioned on the carrier substrate and comprising at least a first layer of a first inorganic material in a first structural phase, and at least a second layer of at least a second inorganic material in at least a second structural phase; and
 - alloy inclusions being formed in the information layer upon exposure to a first electromagnetic radiation and having a structural phase comprising a mixture of the first material in the first structural phase and the at least second material in the at least second structural phase,
 - wherein the optical properties of the alloy inclusions are different from the optical properties of the information layer, as-deposited, so that a modulation in electromagnetic radiation reflected from the alloy inclusions and from an area comprising the as-deposited information layer, respectively, is provided in response to a second electromagnetic radiation being emitted towards the optical information storage medium to provide a read-out signal,
 - wherein the storage medium further comprises:
 - at least one additional layer directly adjacent the carrier substrate and positioned between the carrier substrate and the at least first layer, the at least one additional layer comprising at least one sub-layer being a metal, - wherein a distance between a reflecting surface of the as-deposited information

layer and a reflecting surface of said at least one additional layer is adjusted to be an integer multiple of a quarter wavelength of a second electromagnetic radiation so that interference is obtained between radiation reflected from the surface of the of the as-deposited layer and from the surface of the additional layer,

and wherein said first electromagnetic radiation and said second electromagnetic radiation enter said optical information storage medium opposite to said carrier substrate.

2. (Previously Presented) The optical information storage medium as claimed in claim 1, wherein the inorganic materials at least comprises materials being selected from the group consisting of the pairs: As-Pb, Bi-Cd, Bi-Co, Bi-In, Bi-Pb, Bi-Sn, Bi-Zn, Cd-In, Cd-Pb, Cd-Sb, Cd-Sn, Cd-Ti, Cd-Zn, Ga-In, Ga-Mg, Ga-Sn, Ga-Zn, In-Sn, In-Zn, Mg-Pb, Mg-Sn, Mg-Ti, Pb-Pd, Pb-Pt, Pb-Sb, Sb-Sn, Sb-Ti, Se-Ti, Sn-Ti, and Sn-Zn.

3. (Previously Presented) The optical information storage medium as claimed in claim 1, wherein the inorganic materials at least comprises materials being selected from the group consisting of the pairs: Bi-Co, Bi-In, Bi-Pb, Bi-Sn, Bi-Zn, Ga-In, Ga-Sn, In-Sn, In-Zn, Mg-Sn, Sb-Sn, Sn-Ti, and Sn-Zn.

4. (Previously Presented) The optical information storage medium as claimed in claim 1, wherein the inorganic materials at least comprises the

combination of Bi-In, Bi-Sn, In-Sn.

5. (Previously Presented) The optical information storage medium as claimed in claim 1, wherein each inorganic material has a complex refractive index $n \pm ik$ and wherein the second inorganic material is selected to have a real part of the refractive index lower than the real part of the refractive index of the first material and an imaginary part of the refractive index higher than the imaginary part of the refractive index of the first material.

6. (Previously Presented) The optical information storage medium as claimed in claim 1 wherein the first inorganic material forming the first layer is Bi and the second inorganic material forming the second layer is In or Sn, or wherein the first inorganic material is Sn and the second inorganic material is In.

7. (Previously Presented) The optical information storage medium as claimed in claim 1, wherein the thickness of the first and second layers are selected so that an alloy formed by melting and solidifying of at least a part of the first and second layers has a substantially eutectic composition.

8. (Cancelled).

9. (Previously Presented) The optical information storage medium as claimed in claim 1, wherein the alloy or the as-deposited information layer are

substantially transparent to the second electromagnetic radiation emitted towards the medium.

10. (Previously Presented) The optical information storage medium as claimed in claim 9, wherein the at least one additional layer is adapted to reflect, absorb or diffuse the second electromagnetic radiation being emitted towards the additional layer.

11. (Previously Presented) The optical information storage medium as claimed in claim 9, wherein the at least one additional layer comprises at least one sub-layer comprising a dielectric material.

12. (Cancelled).

13. (Previously Presented) The optical information storage medium as claimed in claim 9, wherein the at least one additional layer comprises at least one transparent spacer layer.

14. (Previously Presented) The optical information storage medium as claimed in claim 1, wherein the medium further comprises a protective cover layer.

15. (Previously Presented) The optical information storage medium as

claimed in claim 1, wherein the modulation in reflected electromagnetic radiation between an area comprising the alloy and an area comprising the as-deposited layer is larger than 70%.

16. (Previously Presented) The optical information storage medium as claimed in claim 1, wherein the modulation is an intensity modulation or a phase modulation.

17. (Previously Presented) The optical information storage medium as claimed in claim 1 wherein the medium is compatible with CD and DVD standards.

18. (Cancelled)

19. (Currently amended) An optical storage information medium comprising:
a carrier substrate,
a first recording stack comprising
a reflective information layer comprising at least a first layer of a first inorganic material in a first structural phase, and at least a second layer of at least a second inorganic material in at least a second structural phase, and at least one additional layer directly adjacent the carrier substrate and positioned between the carrier substrate and the at least first layer, the at least one additional layer comprising at least one sub-layer being a metal, wherein a

distance between a reflecting surface of the as-deposited information layer and a reflecting surface of said at least one additional layer is adjusted to be an integer multiple of a quarter wavelength of a second electromagnetic radiation,

alloy inclusions being formed in the information layer and having a structural phase comprising a mixture of the first material in the first structural phase and the at least second material in the at least second structural phase,

a separation layer,

a second recording stack substantial identical to the first recording stack,

and wherein a first electromagnetic radiation and said second electromagnetic radiation enter said optical information storage medium opposite to said carrier substrate.

20. (Currently amended) A method for manufacturing an optical information storage medium, the method comprising the steps of:

providing a carrier substrate,

providing a reflective information layer by depositing at least a first layer of a first inorganic material in a first structural phase on the carrier substrate, and depositing at least a second layer of at least a second inorganic material in a second structural phase on the first layer,

providing at least one additional layer directly adjacent the carrier substrate and positioned between the carrier substrate and the at least first layer, the at least one additional layer comprising at least one sub-layer being a metal,

wherein a distance between a reflecting surface of the as-deposited information layer and a reflecting surface of said at least one additional layer is adjusted to be an integer multiple of a quarter wavelength of an electromagnetic radiation for reading said optical information storage medium, said electromagnetic radiation entering said optical information storage medium opposite to said carrier substrate,

the at least first and second inorganic materials being selected so that a structural phase being formed by melting and solidification of at least a part of the information layer provides alloy inclusions having a structural phase comprising a mixture of the first material in the first structural phase and the second material in the second structural phase.

21. (Previously Presented) The method as claimed in claim 20, further comprising the step of exposing in a predetermined pattern the information layer to a first electromagnetic radiation so as to form alloy inclusions in the exposed information layer.

22. (Currently amended) An optical information storage medium being provided by the method comprising:

providing a carrier substrate,

providing a reflective information layer by depositing at least a first layer of a first inorganic material in a first structural phase on the carrier substrate, and depositing at least a second layer of at least a second inorganic

material in a second structural phase on the first layer,

providing at least one additional layer directly adjacent the carrier substrate and positioned between the carrier substrate and the at least first layer,
the at least one additional layer comprising at least one sub-layer being a metal,
wherein a distance between a reflecting surface of the as-deposited information layer and a reflecting surface of said at least one additional layer is adjusted to be an integer multiple of a quarter wavelength of an electromagnetic radiation for reading said optical information storage medium, said electromagnetic radiation entering said optical information storage medium opposite to said carrier substrate,

the at least first and second inorganic materials being selected so that a structural phase being formed by melting and solidification of at least a part of the information layer provides alloy inclusions having a structural phase comprising a mixture of the first material in the first structural phase and the second material in the second structural phase
as claimed in claim 20.

23. (Currently amended) A method for optically reading an optical information storage medium comprising a carrier substrate, a reflective information layer being positioned on the carrier substrate and comprising at least a first layer of a first inorganic material in a first structural phase, and at least a second layer of at least a second inorganic material in at least a second structural phase; and an alloy inclusions being formed in the information layer upon exposure to a first

electromagnetic radiation and having a structural phase comprising a mixture of
the first material in the first structural phase and the at least second material in
the at least second structural phase, wherein the optical properties of the alloy
inclusions are different from the optical properties of the information layer, as-
deposited, so that a modulation in electromagnetic radiation reflected from the
alloy inclusions and from an area comprising the as-deposited information layer,
respectively, is provided in response to a second electromagnetic radiation being
emitted towards the optical information storage medium to provide a read-out
signal, wherein the storage medium further comprises at least one additional
layer directly adjacent the carrier substrate and positioned between the carrier
substrate and the at least first layer, the at least one additional layer comprising
at least one sub-layer being a metal, wherein a distance between a reflecting
surface of the as-deposited information layer and a reflecting surface of said at
least one additional layer is adjusted to be an integer multiple of a quarter
wavelength of a second electromagnetic radiation as claimed in claim 1, the
method comprising the steps of:

emitting an electromagnetic radiation towards the optical information storage medium,

detecting a phase or intensity modulation in electromagnetic radiation reflected from the optical information storage medium in response to the incoming electromagnetic radiation,

so that a pattern of alloy inclusions in the as-deposited information layer is provided by the detected phase or intensity modulation.